Constant Color

U.S. Application of FINK et al., Appls. No. 10/705,224 atty. dks. 071469-0305806

IN THE CLAIMS:

This listing of claims will replace all prior versions, and listings, of claims in the application:

- (Currently Amended) A baffle plate assembly for surrounding a substrate holder in a plasma processing system comprising:
- a centering ring configured to be coupled to said substrate holder, wherein at least a portion of said centering ring extends radially outside a periphery of said substrate holder; and
- a <u>removable</u> baffle plate comprising one or more passageways, wherein said baffle plate is configured to be centered within said plasma processing system by <u>removably</u> coupling said baffle plate to said portion of said centering ring extending radially outside said periphery of said substrate holder.
- 2. (Original) The baffle plate assembly of claim 1, wherein said centering ring is coupled to said substrate holder using fasteners.
- 3. (Original) The baffle plate assembly of claim 1, wherein said centering ring comprises a centering feature configured to center said haffle plate on said centering ring.
- 4. (Original) The baffle plate assembly of claim 3, wherein said centering feature comprises at least one of a centering pin, a centering recuptacle, a centering edge, and radial face gear teeth.
- 5. (Original) The baffle plate assembly of claim 3, wherein said baffle plate comprises a mating feature configured to be coupled with said centering feature.
- 6. (Original) The baffle plate assembly of claim 5, wherein said mating feature comprises at least one of a centering pin, a centering receptacle, a centering edge, and radial face gear teeth.

400404045_1.DOC